

S/N TBD
Docket: CS03-048
Group art unit : __ TBD

Date 1/30/04

**To: Commissioner of Patents and Trademarks
P.O. Box 1450 Alexandria, VA 22313-1450**

**Fr: William J. Stoffel Reg. No. 39,390 CUST NO. 30402
PMB 455
1735 Market St - Suite A
Philadelphia, PA 19103**

Subject:

Serial No. TDB
Docket cs03-048
File Date: with application
Inventor: Li et al.

**title: A SEMICONDUCTOR DEVICE LAYOUT AND CHANNELING
IMPLANT PROCESS**

INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO A820 (also PTO-1449), Information Disclosure Citation and references.

CERTIFICATE OF MAILING OR EXPRESS MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail or Express mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450, on Jan 30, 2004.

Signature/Date Will J. Stoffel 1/30/04
William J. Stoffel Reg. No. 39,390
Customer number 30402

S/N TBD
Docket: CS03-048
Group art unit : __ TBD

The following Patents and/or Publication are submitted to comply with the duty to disclose under CFR 1.97-1.99 and 37 CFR 1.56.

US 5,970,300(Buynoski) shows a I/I process.

US 5,729,045(Buynoski) shows a I/I process for S/D.

US 6,566,204(Wang, et al.) teaches the use of mask shadowing and angled implantation in fabricating asymmetrical field-effect transistors.

US 6,599,804(Bulucea, et al.) shows a fabrication of field-effect transistor for alleviating short-channel effects.

US 4,728,617(Woo, et al.) shows a method of fabricating a MOSFET with graded source and drain regions.

Sincerely,



William J. Stoffel
Reg. No. 39,390
Customer number 30,402

INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i>				Docket Number (Optional)		Application Number	
				CS03-048			
				Applicant(s) Yisuo Li			
U.S. PATENT DOCUMENTS				Filing Date		Group Art Unit	
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		US 5,970,300		(Buynoski)			
		US 6,566,204		(Wang, et al.)			
		US 6,599,804		(Bulucea, et al.)			
		US 4,728,617		Woo, et al			
		US 5,729,045		Buynoski			
FOREIGN PATENT DOCUMENTS							
REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>							
EXAMINER				DATE CONSIDERED			
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.